



OPIE DOCKET NO.: 279648US0PCT

IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:
Kanematsu NATSUME, et al.

GROUP: 1745

SERIAL NO: 10/554,397

ATTENTION:
FILING RECEIPT CORRECTIONS

FILED: September 26, 2006

FOR: NEGATIVE ELECTRODE FOR LITHIUM SECONDARY CELL, LITHIUM SECONDARY CELL EMPLOYING THE NEGATIVE ELECTRODE, FILM DEPOSITION MATERIAL B USED FOR FORMING NEGATIVE ELECTRODE, AND PROCESS FOR PRODUCING NEGATIVE ELECTRODE

REQUEST FOR CORRECTED OFFICIAL FILING RECEIPT

Office of Initial Patent Examination
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The Patent Office is requested to provide a corrected Official Filing Receipt for the following.

PLEASE NOTE THAT THE ASSIGNMENT FOR PUBLISHED PATENT APPLICATION DATA IS MISSING. IT SHOULD READ AS FOLLOWS:

SUMITOMO TITANIUM CORPORATION, HYOGO, JAPAN.

No fees are required. If you have any questions, please do not hesitate to contact us.

Respectfully Submitted,

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UNITED STATES PATENT AND TRADEMARK OFFICE

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY.DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/554,397	09/26/2006	1745	1430	279648US0PCT	3	18	5

CONFIRMATION NO. 2754

22850
 C. IRVIN MCCLELLAND
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 ALEXANDRIA, VA 22314

FILING RECEIPT



OC000000021445479

Date Mailed: 12/04/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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 Tadashi Ogasawara, Hyogo, JAPAN;

Kazuomi Azuma, Hyogo, JAPAN;

Assignment For Published Patent Application
 SUMITOMO TITANIUM CORPORATION, HYOGO, JAPAN.

Power of Attorney: The patent practitioners associated with Customer Number 22850.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/05527 04/16/2004

Foreign Applications

JAPAN 2003-123938 04/28/2003
 JAPAN 2003-295363 08/19/2003
 JAPAN 2003-297443 08/21/2003
 JAPAN 2003-299701 08/25/2003

RECEIVED: 12/6/06OBLON, SPIVAK, McCLELLAND
 MAIER & NEUSTADT, P.C.DOCKETING DEPT. PP 12/17/06

Initials/Date Docketed:

Type of Response:

Due Date(s):

If Required, Foreign Filing License Granted: 12/01/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/554,397**

Projected Publication Date: 03/15/2007

Non-Publication Request: No

Early Publication Request: No

Title

Negative electrode for lithium secondary cell, lithium secondary cell employing the negative electrode, film deposition material b used for forming negative electrode, and process for producing negative electrode

Preliminary Class

429

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